DOCKET NO: 250235US-3

INVENTOR: Shinji KOBAYASHI, et al.

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IN THE SPECIFICATION

Please delete the paragraph beginning at page 9, lines 17-20.

Please amend the paragraph beginning at page 9, lines 21-23:

Fig. 19 20 is a graph three-dimensionally showing a thickness distribution of a resist film formed on a substrate by using a conventional method.